

19 May (sun)	20 May (Mon)					21 May (Tue)					22 May (Wed)					23 May (Thu)					
	Room A					Room A	Room B	Room C	Room D	Room E	Room A	Room B	Room C	Room D	Room E	Room A	Room B	Room C	Room D	Room E	
	CSW 2019 Opening 8:30-8:40					TuA1 8:30-10:30	TuB1 8:30-10:30	TuC1 8:30-10:30	TuD1 8:30-10:30	TuE1 8:30-10:30	WeA1 8:30-10:00	WeB1 8:30-10:00	WeC1 8:30-10:00	WeD1 8:30-10:00	WeE1 8:30-10:00	ThA1 8:30-10:30	ThB1 8:30-10:30	ThC1 8:30-10:30	ThD1 8:30-10:30		
	CSW 2019 Plenary MoPLN1-1 8:40-9:20					Nanomechanics, Thermal and phonon transport	GaN MOS Power FETs	Growth and Sensor of 2D Materials	Ga2O3 Bulk and Epitaxial Growth	hBN : Growth I	GaN and Related Technologies II	Photovoltaic and LED	Nanowire Devices	Quantum Dots and Coherent dynamics	Organic Devices	Growth of Nanostructures and Quantum-Effect Devices	Novel Photonics	Oxides: Doping	GaN and Related Technologies IV	ThE1 9:00-10:30	Organic and Perovskite materials
	CSW 2019 Plenary MoPLN1-2 9:20-10:00																				
	Coffee Break 10:00-10:30																				
	CSW 2019 Plenary MoPLN2-1 10:30-11:10					Coffee Break 10:30-11:00					WeA2 10:30-12:00	WeB2 10:30-11:45	WeC2 10:30-12:00	WeD2 10:30-12:00	WeE2 10:30-12:00	Coffee Break 10:30-11:00					
	CSW 2019 Plenary MoPLN2-2 11:10-11:50					TuA2 11:00-12:30	TuB2 11:00-12:30	TuC2 11:00-12:30	TuD2 11:00-12:30	TuE2 11:00-12:30	GaN and Related Technologies III	Mid Infrared Photonics	Fabrication of Nanostructures	Spin Transport and Dynamics	THz Devices	ThA2 11:00-12:30	ThB2 11:00-12:30	ThC2 11:00-12:30			
	IPRM/ISCS Award Ceremony & Photo 11:50-12:30					Superconductor-Semiconductor Hybrid Structures	Quantum Dot Lasers	RF and on-Si Technology	Ga2O3 Process and Characterization	hBN : Point Defects						Advanced Epitaxial Growth Techniques of III-V Materials	Photodetectors	GaN Power Devices and Characterization			
	Lunch Time 12:30-14:00					Lunch Time 12:30-14:00					Closing and Student Award Ceremony 12:45-13:30										
Registration 12:30-18:00	Room A MoA3 14:00-16:00	Room B MoB3 14:00-16:00	Room C MoC3 14:00-16:00	Room D MoD3 14:00-16:00	Room E MoE3 14:00-16:00	Room A TuA3 14:00-16:15	Room B TuB3 14:00-16:00	Room C TuC3 14:00-16:00	Room D TuD3 14:00-16:00	Room E TuE3 14:00-16:00	Excursion 12:30-18:00										
Special Lecture I 15:00-16:00	Advanced Lasers	Growth of Nitrides	Electrical and Optical Devices of 2D Materials	GaN and Related Technologies I	Oxides: Structures and Properties	Advanced Photonic Integration	Epitaxial Growth on Group IV Substrates	Characterization of Nanostructures	Ga2O3 Electrical Devices	hBN : Spectroscopy and Growth II											
Coffee Break 16:00-16:30	Poster Session I 16:00-18:00					Poster Session II 16:00-18:00															
Special Lecture II 16:30-17:30																					
Reception 18:00-20:00	Social Program I 18:00-19:00					Social Program II 18:00-19:00					Banquet 18:30-21:00										

- A: Epitaxy, fabrication, and related technologies
- B: RF electron devices
- C: High power electron devices
- D: Photonic devices and related technologies
- E: Physics, spintronics, and novel device concepts
- F: Nanocharacterization and nanostructures
- G: GaN and related semiconductors
- H: Oxide semiconductors
- I: Nanocarbon and novel 2D materials
- J: Organic semiconductors and flexible materials
- SS1: (Special session) Gallium oxide: materials and devices
- SS2: (Special session) Hexagonal boron nitride